

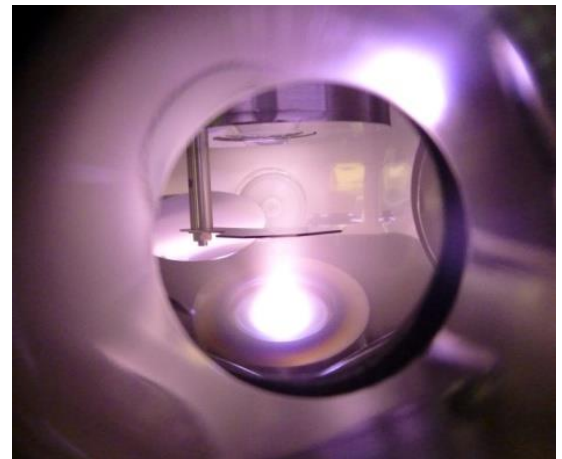
Sputtering Equipment

Feature

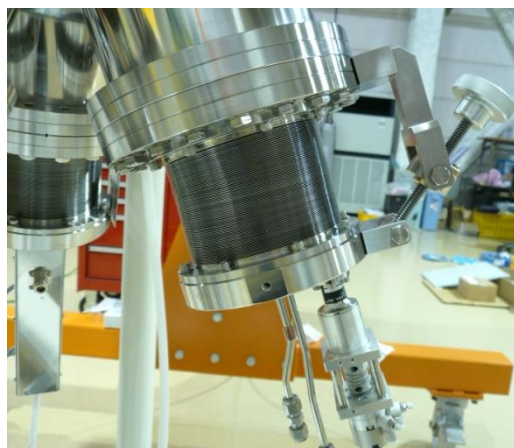
- 2- or 3-inch Sputter Gun is prepared as standard feature. Special size order is also available
- Available magnet type selection and design in order to realize a stable electric discharge to wide variety of target
- Selectable heater source of lamp or sheathed heater for substrate. Available maximum 3-inch substrate and maximum 800°C operation temperature (special order)
- Available an efficient film deposition by automatic operation



Ternary Sputtering equipment for 2-inch substrate



Discharge Condition



3-inch splutter gun with inclined bellows



3-inch splutter gun

※ Refer to another page for special sputter gun.